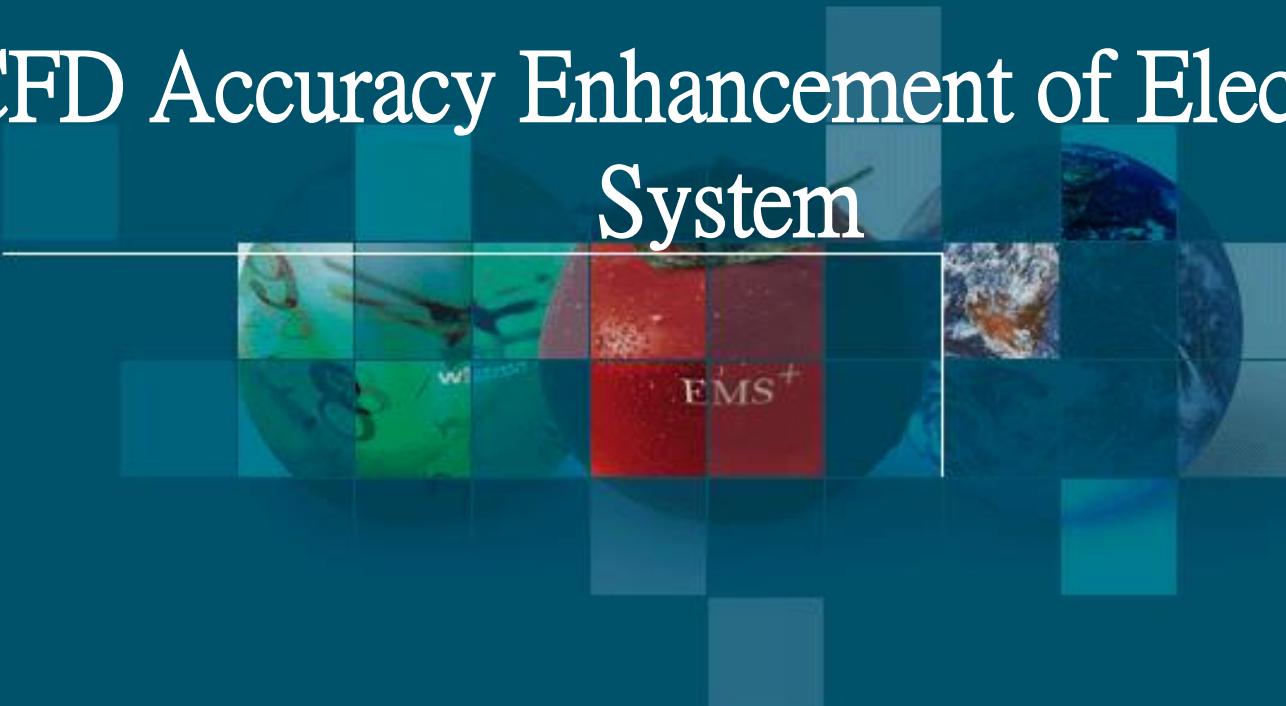
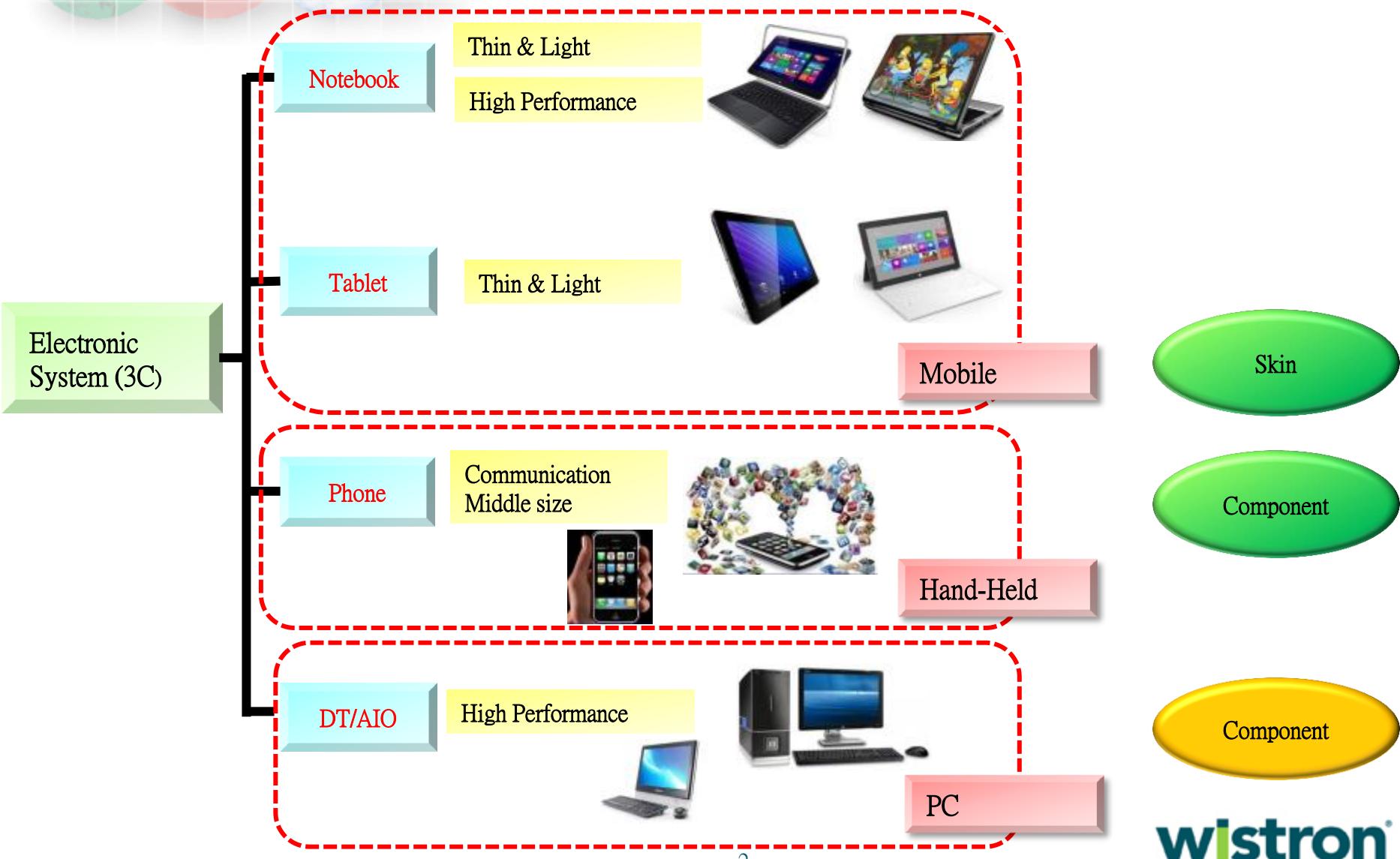


# CFD Accuracy Enhancement of Electronic System

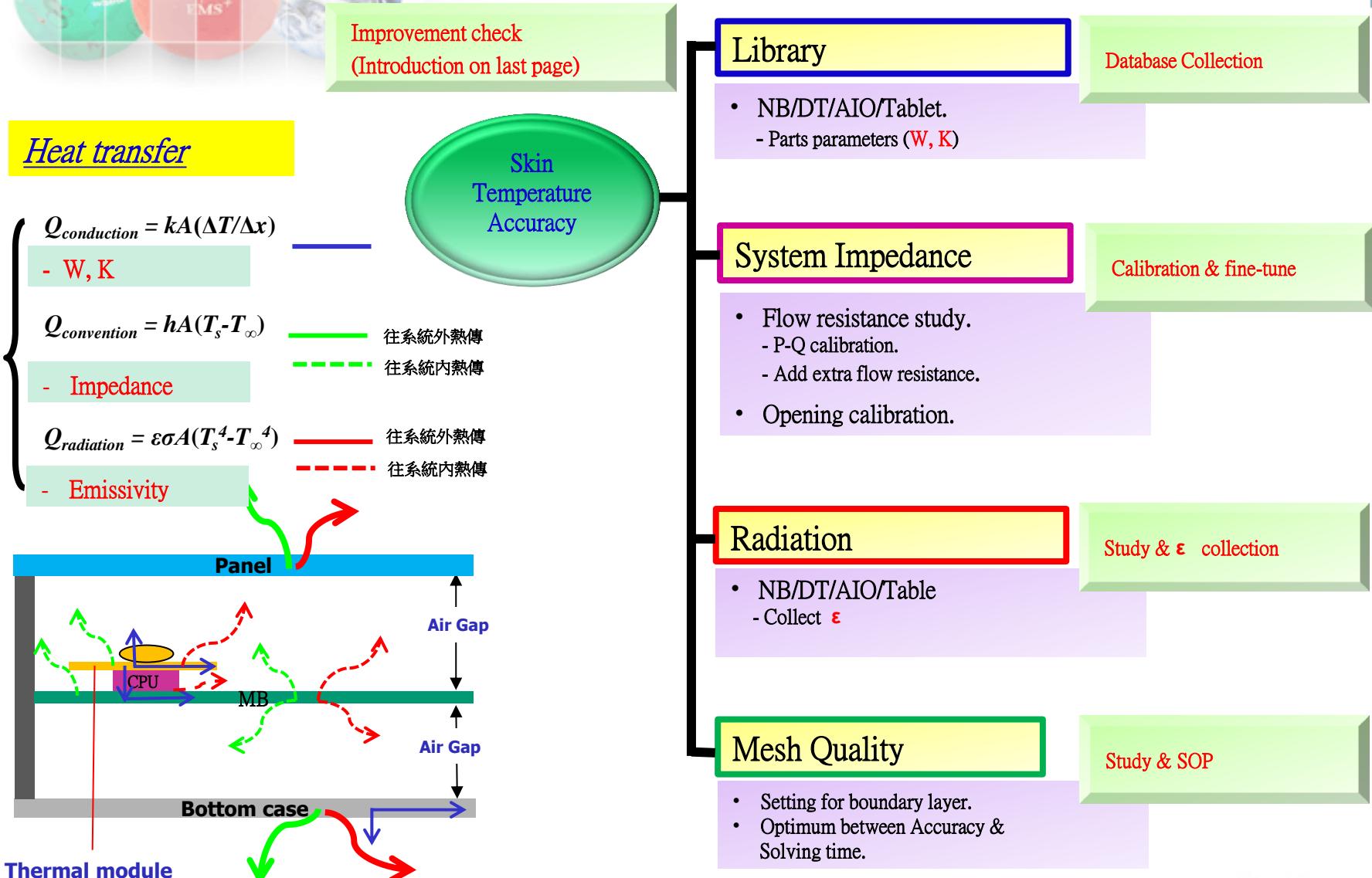


*CAE/CFD Analysis Dev. Dept.  
Structure & Thermal Design Center  
Wistron Corporation  
1CTA00 Iring Chiou  
Date : 2014-11-03*

# Product Line



# Skin Temperature Accuracy Improvement



# Library Collection(I)

## - Wistron Library\_20140923

- DT\_AIO\_RPOS
- NoteBook Library
- Tablet Library

- DT\_AIO\_RPOS
  - + CPU
  - + HDD
  - MB
  - + Memory
  - + PCH
  - + PSU



- NoteBook Library
  - + CPU
  - + Camera
  - + GPU
  - + HDD
  - MB
  - + Memory
  - + Mini PCI Card
  - + North Bridge
  - + PCH
  - + Second Part
  - + South Bridge
  - + System resistance
  - + Thermal Module

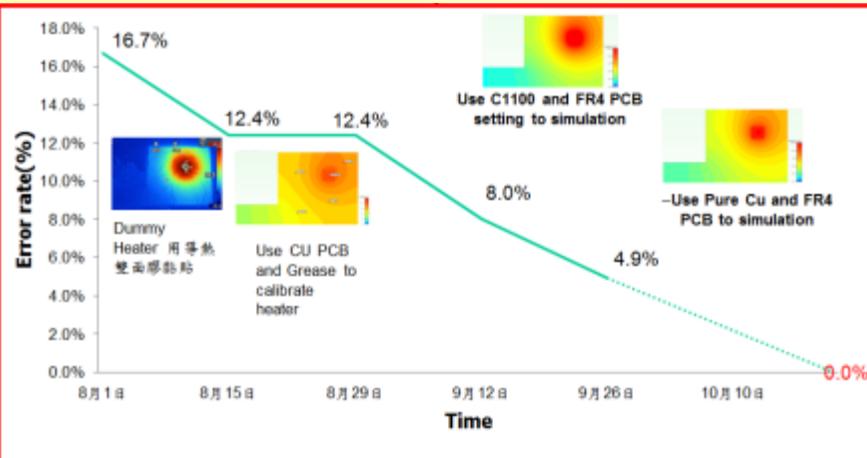


- Tablet Library
  - + CPU
  - + EE component
  - + External Card
  - + LCD
  - MB

# Library Collection(II)

## PCB

1. The temperature distribution of MB will impact distribution of skin temperature.
2. Estimated Kz from Theory & Experiment(Follow ASTM 5470測試規範)



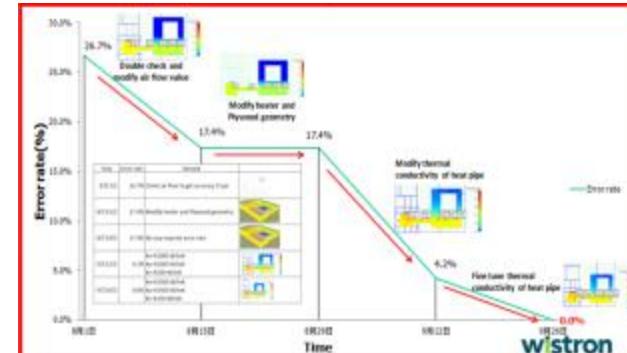
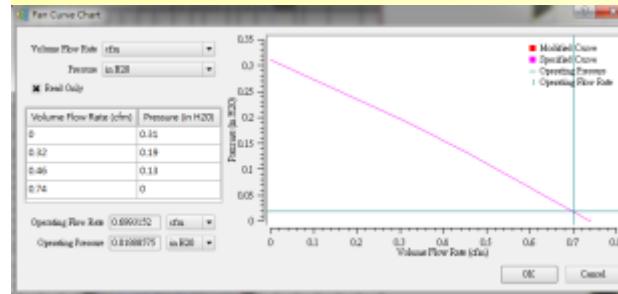
Error rate decrease from 16.7% to 4.9%

## Thermal Module

### Heat-Pipe

### Fan PQ

1. Modified PQ Curve in free air condition.  
(Refer Intel's document)
2. Calibrated conductivity of heat pipe
  - a. The error come form soldering & different structure(Powder/composite/groove)

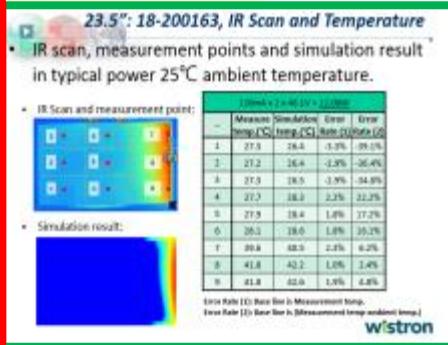
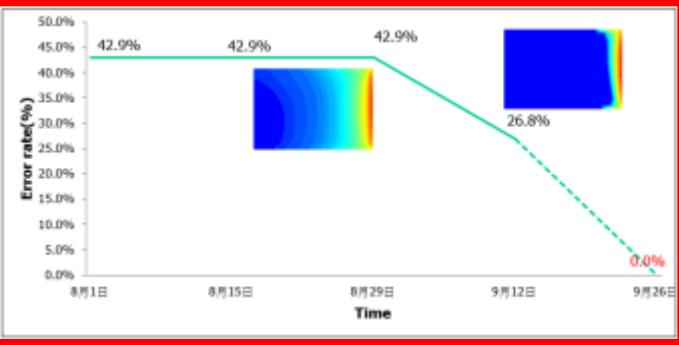


Error rate decrease from 26.7% to 4.2%

# Library Collection(III)

## Panel

1. Decompose
  - a. confirm Z-stacking of different vendor
  - b. backlight power & LCD power
2. Calibrate conductivity of LCM

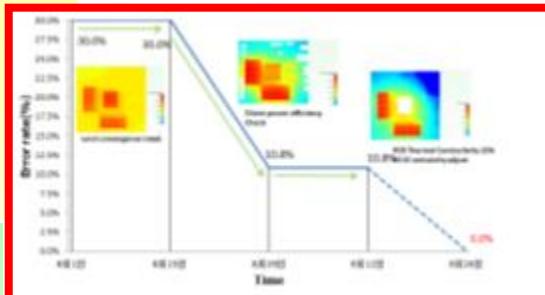


Error rate decrease from 42.9% to 20% (Still on-going)

## Memory

1. Confirm Input power
  - a. different vendor & capacity
  - b. different stacking type
  - c. UMA/DIS
  - d. different scenario

Error rate decrease from 30.0% to 10.8% (Still on-going)



Error rate decrease from 25.0% to 5.9%

## VRM

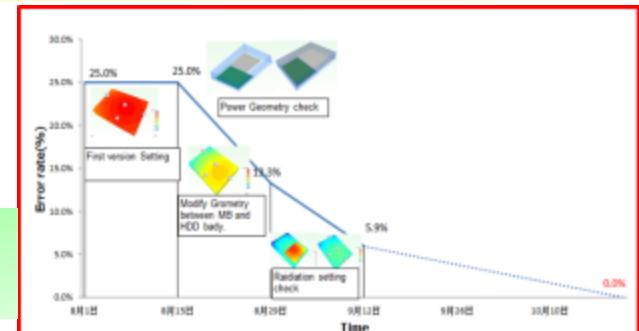
1. Decompose
  - a. Calibrated conductivity of chock/mos
  - b. Analyzed by "Taguchi-method"



Error rate decrease from 13.8% to 6.9%

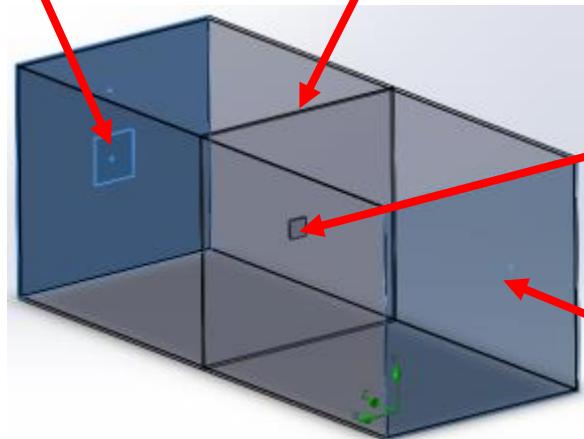
## HDD

1. Confirm Input power
  - a. different vendor & capacity
  - b. different scenario
  - c. UMA/DIS



# System Impedance

Negative Pressure



Enclosure  
500Wx500Hx600Lmm  
Thickness 5mm  
No slip Wall, roughness = 0

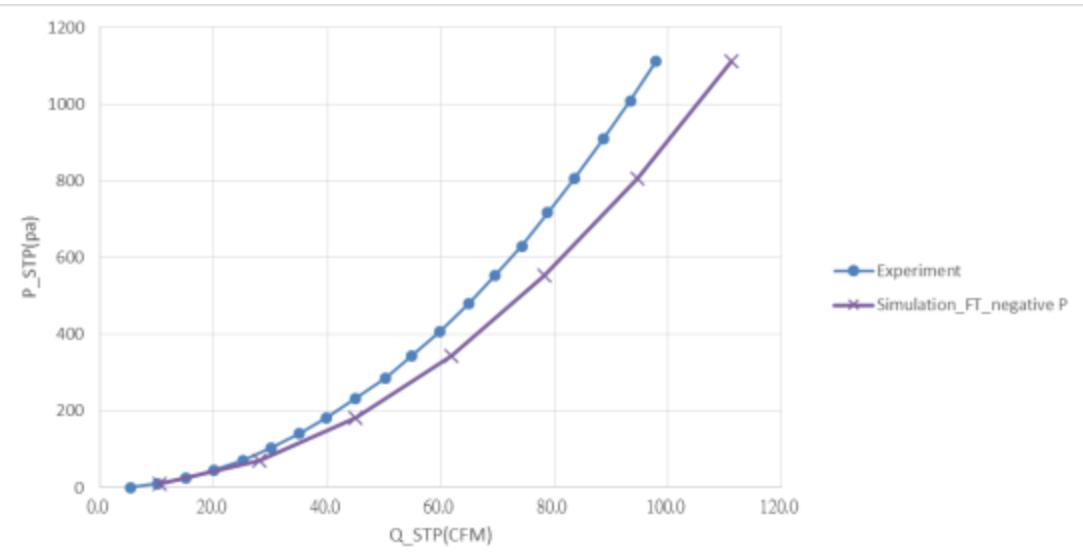
Square Hole  
40Wx40Hmm

Environment Pressure  
1atm

Solution Domain: 500Wx500Hx1000L mm  
Symmetry Boundary set on  $\pm Y$  and  $\pm X$

## Study items:

1. Check Setting of Numerical tunnel
2. Studying outlet vent
3. Studying inlet vent
4. Studying whole thermal module.



# Radiation – Calibrate emissivity



★試算表

## Theory

$$Q_{total} = Q_{convection} + Q_{radiation}$$

$$[Q_{rad} = \epsilon \sigma A (T_s^4 - T_a^4)]$$

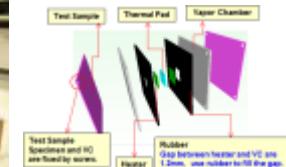
$$[Q_{conv} = hA(T_s - T_a)]$$

(Ta: 室溫 Ts: 試片溫度)

理論公式整理成的試算表做分析

分析Convection & Radiation各面熱傳量(Q)  
並理論分析結果比較

目標  
求得未知試  
片放射率?



由理論公式及概  
念設計實驗治具

## Numerical(FT) Step2

1. 輸入  $w, T_a$

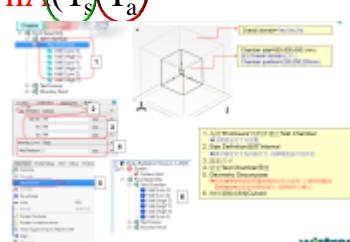
2. Tuning  $\epsilon$  直到實驗的試片表面溫度與模擬結果一致。

建立 CFD model

## Experiment Step1

【輸入固定功率，量測試片表面溫度】

$$Q_{total} = \epsilon \sigma A (T_s^4 - T_a^4) + hA(T_s - T_a)$$



★SOP  
★Golden model

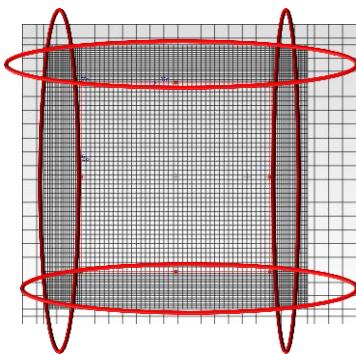
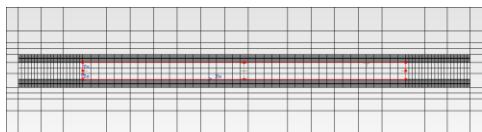
★SOP



# Mesh quality

## Mesh quality

It will help to show boundary effect, if make suitable grid setting on boundary of object or heat source.

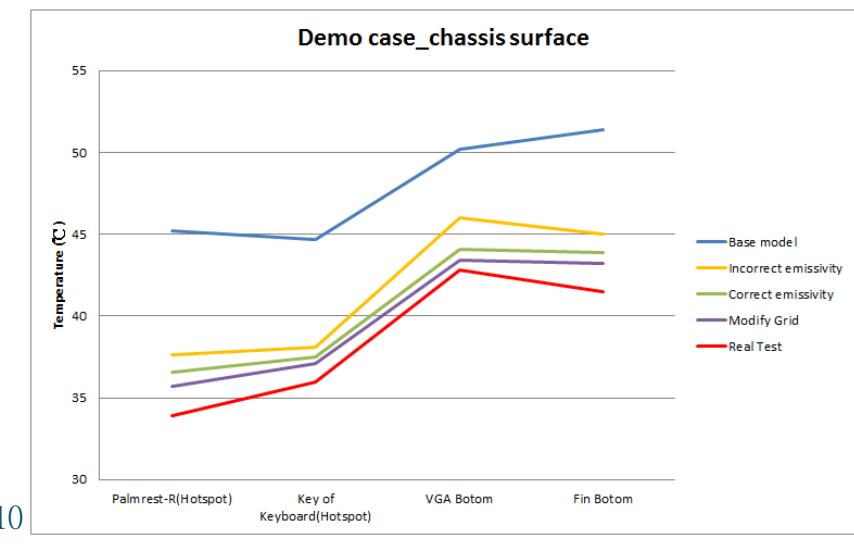
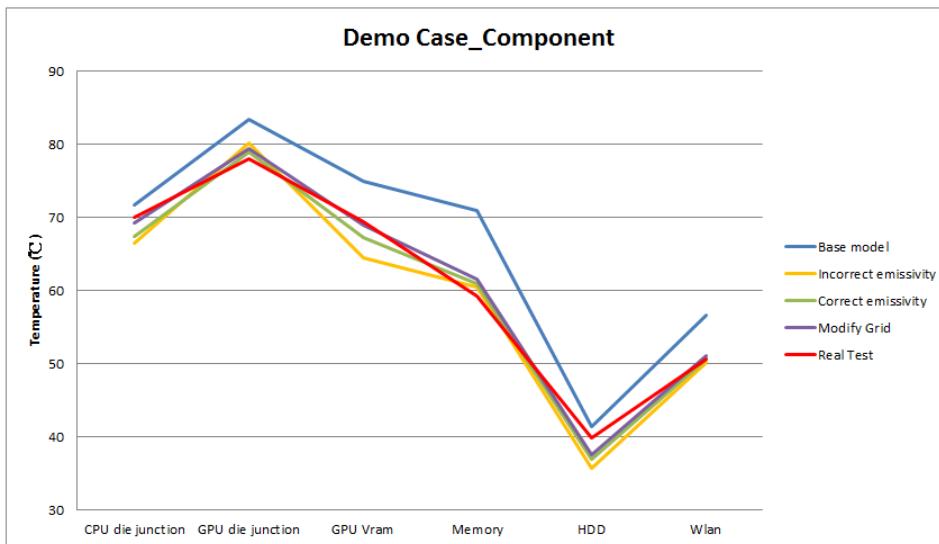


Heater Calibration: Real test=103.6°C

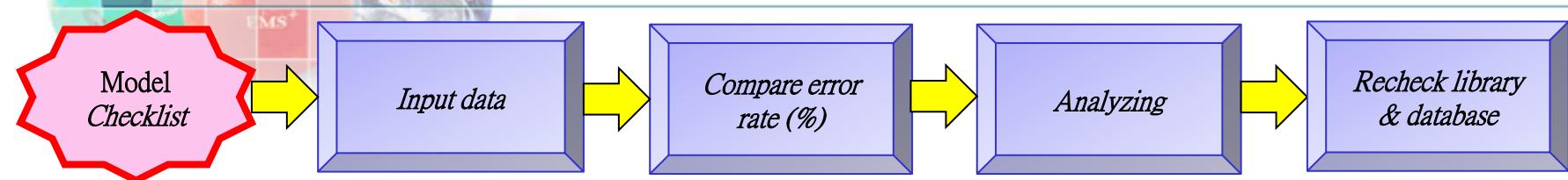
1		2		3	
No boundary mesh	Error rate(%)	Boundary mesh (0.2 mesh size)	Error rate(%)	Boundary mesh (0.5 mesh size)	Error rate(%)
106.2°C	2.5%	103.9°C	0.2%	104.3°C	0.8%

# Demo Case

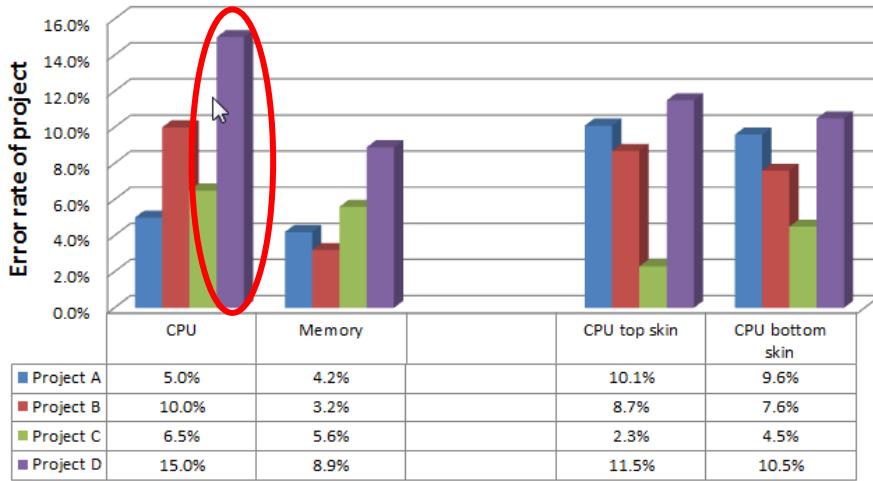
		Base model		Incorrect emissivity		Correct emissivity		Modify Grid		Real Test
System Radiation		OFF		ON		ON		ON		-
Power	System total	36.65		36.5		36.65		36.65		36.3
Component	Scenario	3DMark13	Error	3DMark13	Error (%)	3DMark13	Error (%)	3DMark13	Error (%)	
	CPU die junction	71.6	2.3%	66.4	-5.1%	67.4	-3.7%	69.2	-1.1%	70.0
	GPU die junction	83.3	6.8%	80.1	2.7%	78.8	1.0%	79.3	1.7%	78
	GPU Vram	74.9	8.1%	64.4	-7.1%	67.1	-3.2%	68.9	-0.6%	69.3
	Memory	70.8	<b>19.8%</b>	60.4	2.2%	60.9	3.0%	61.5	4.1%	59.1
	HDD	41.3	3.8%	35.7	<b>-10.3%</b>	36.9	-7.3%	37.4	-6.0%	39.8
	Wlan	56.6	<b>12.1%</b>	50.1	-0.8%	50.5	0.0%	51.0	1.0%	50.5
Skin	Palmrest-R(Hotspot)	45.2	<b>33.3%</b>	37.6	<b>10.9%</b>	36.6	8.0%	35.7	5.3%	33.9
	Key of Keyboard(Hotspot)	44.7	24.2%	38.1	5.8%	37.5	4.2%	37.1	3.1%	37.9
	VGA Botom	47.8	17.3%	44.0	7.5%	43.5	3.0%	43.0	1.4%	44.6
	Fin Botom	51.4	23.9%	45.0	8.4%	43.9	5.8%	43.2	4.1%	41.5



# Process about improving accuracy



Analysis of error rate between simulation & experiment data



Ex: CPU temp. have larger error rate occurs on project D

Analyzing: CPU (new platform) in project-D & crate by CPU spec.  
Recheck: According calibration SOP & build new CPU model in library

Create new CPU model in library

Refer to "Calibration SOP"

## Parameters (ProjectD)

Key component	Conductivity(k)	Emissivity( $\epsilon$ )	選擇 New Create & others 請註明
CPU	New create	Library	MTK CPU(create by CPU spec.)
Memory	Library	Library	
UCASE	New create	Database	Special ID
LCASE	New create	Database	Special ID